



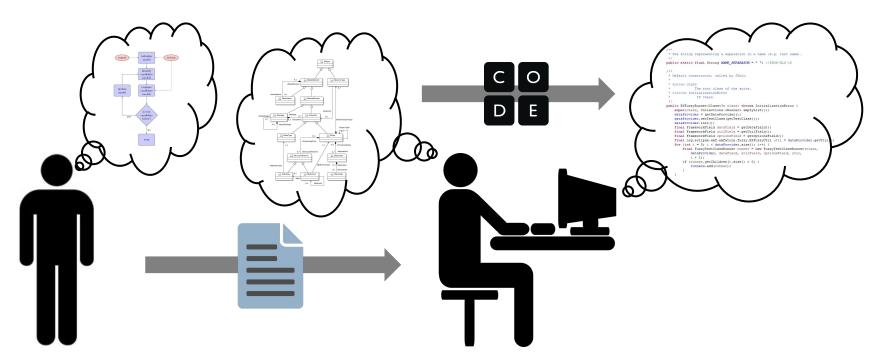
Papyrus Industry Consortium Open Source Model-based Engineering Tools in Industry

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Context: Model-based Engineering (MBE)

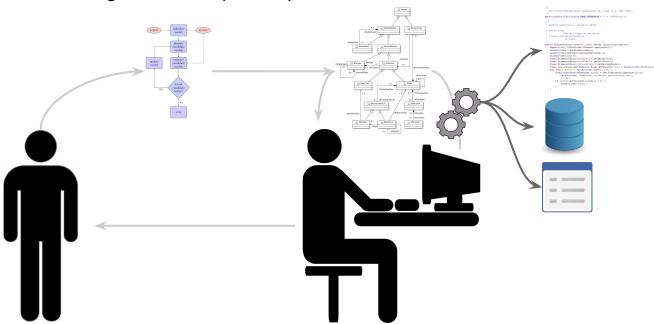
- Problem
 - Every software/system is built around a model / specification
 - o Data model, interactions, protocol specifications, architectures, ...





Context: Model-based Engineering (MBE)

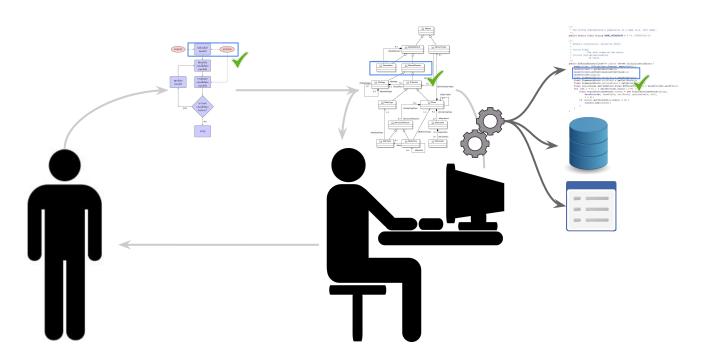
- Basic idea
 - Turn those implicit or non-formal models explicit and formal models
 - Ease the communication among domain experts
 - Exploit those along the development process





Context: Model-based Engineering (MBE)

- Basic idea
 - Early validation, simulation & debugging, continuous integration, traceability
 - Automation of the development: codegen, interpretation

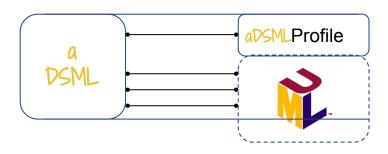




Context: Domain-specific Modeling (DSM)

- MBE is most successful if it is domain-specific
 - Highly customized modeling environments
 - Directly reflecting specific needs of a domain and its users
 - User roles and their backgrounds (systems architect, electrical engineer, ...)
- General-purpose modeling language vs DSM language
 - This is NOT about UML vs. DSML (= non-UML)
 - But about plain UML vs. UML & UML profiles (= DSML)







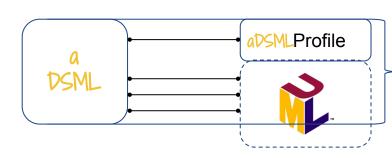
Context: Domain-specific Modeling (DSM)

- A DSML is not enough
 - DSML and its modeling tool is one single product
 - Factor in users' domain, objectives, and their background
 - Domain users, potentially different user types and roles
 - Customizability is key
 - Language and its concrete syntaxes (diagrams, tables, trees, text)
 - Customizability of the editing tools (less is more)
 - Flexibility of the environment (integration with existing tools)











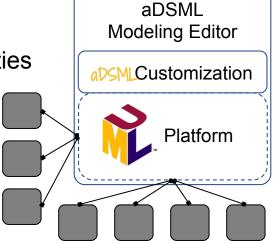


Why Open Source Platform?

An off-the-shelf modeling tool is not enough

Industrial use cases require lots of additional capabilities

- CodeGen
- Validation, simulation
- Model checking, model testing
- Collaborative modeling, PLM
- 0 ...
- Flexibility and customizability is key
- Commercial off-the-shelf tools cannot provide all that
 - No single organization has the capacity and expertise to create all those capabilities
 - Off-the-shelf modeling tools are not customizable enough.
 - They cannot grow a community that fills those gaps





Why Open Source Platform?

- Open Source is not free
- Shared maintenance costs of shared parts
- It is not about the money, it is about flexibility and evolution
 - Innovation in MBE development techniques don't depend on single SW vendors
 - Closed source → inflexible, hard to extend, customize, adapt, ...
 - Vendor lock-in is a huge long-term risk
- Consumers usually don't gain a USP from the modeling environment itself
 - Value is in the domain-specific models, DSMLs and what the they are used for
 - Customizations are key though



Papyrus



- Eclipse-based modeling platform
 - Standards-based: UML, SysML, OCL, fUML, Alf, MARTE, ...
 - Domain-specific languages with UML Profiles
 - Truly open: Eclipse Public License at Eclipse License EPLLO
 - Customizable concrete syntax: diagrams, tables, trees, text
 - Enabler for model-based technologies
 - simulation, formal testing, safety analysis, trade-offs analysis, exploration, ...
- Many successful industrial applications
 - https://eclipse.org/papyrus/testimonials.html





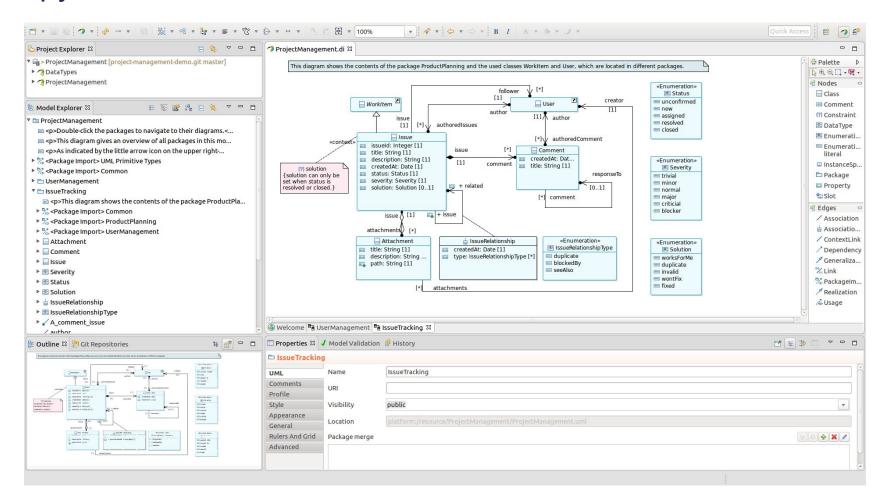






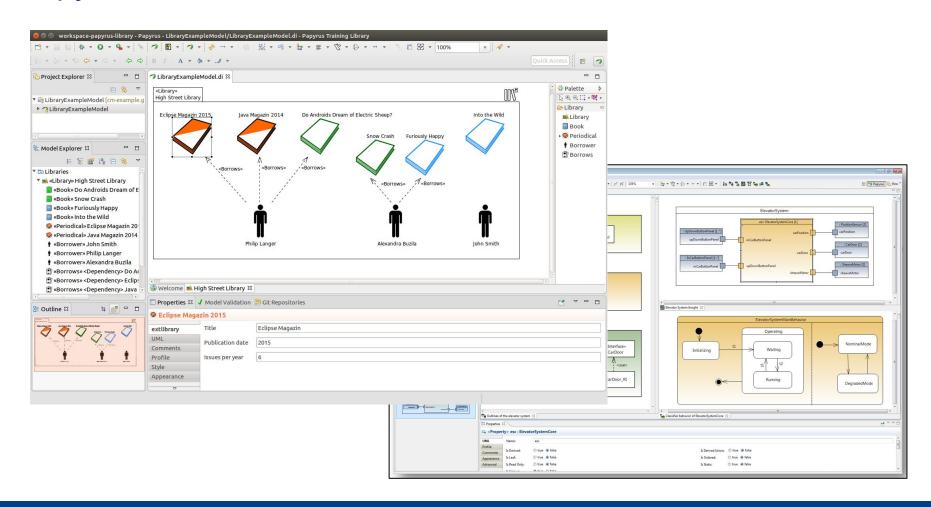


Papyrus





Papyrus





Papyrus Industry Consortium (PIC)



- Open consortium with a common goal
 - Developing a universal, industry-ready, open-source MBE solution
 - Based on Eclipse Papyrus and many other open-source components
- Independent of the domain
 - Systems modeling
 - Architecture modeling
 - Enterprise modeling
 - Internet of Things
 - CPS
 - 0 ...
- Strong collaboration
 - Tool users
 - Tool suppliers
 - Research and academia



PIC Objectives



- Development of industrial-grade open source solution
- Joint development financing
- Knowledge sharing
- Promotion of open source solution
- Development of the community
- Standardization
- Collaboration on research projects
- Contribution to MBE education and training
- ..



Papyrus Industry Consortium (PIC)



User Lead Members







Supplier Lead Members











Participant Members









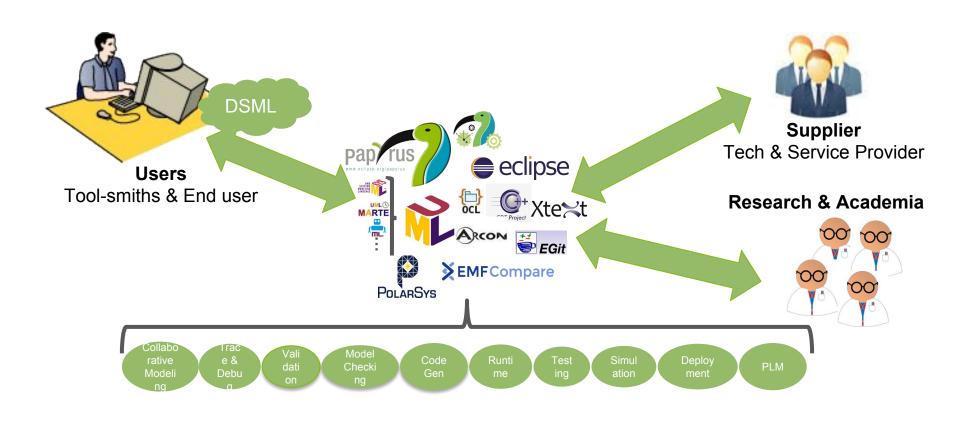






PIC Ecosystem







PIC Ecosystem

- Users: Tool smiths and end users
 - Customizable open tool platform
 - Free to evolve, extend, and use
 - Independent from single vendors
 - Distribution of development and maintenance costs
 - Coordination of objectives and investments
 - Exchange of experiences and best practices







PIC Ecosystem



- Supplier: Technology/Service Provider
 - Allows to focus on expertise
 - Open-source is proof-of-expertise
 - Open market without non-technical entry barriers
 - Knowledge and reputation is everything
 - Independence from other technology providers

Research & Academia

- Open access to platforms for research prototype
- Without being able to modify the platform it is hard to innovate
- Easier transfer of requirements from practice
- Enables more direct evaluations and case studies in practice
- Easier knowledge and technology transfer into practice







Many challenging research topics



- Hybrid modeling
 - Synchronized graphical and textual modeling
- Collaborative modeling
 - Model review, concrete syntax oriented diff / merge
- Quality assessment of models
- Security in modeling and security modeling
- Several more
 - See https://wiki.polarsys.org/Papyrus_IC/Research_Academia/Research_priorities









Summary



- Open source is the only practical way to full MBE
- Eclipse, EMF, and Papyrus provide the basis for this vision
- A vibrant and extensive community is key
- Contributions from research & academia are essential
- An outstanding opportunity for all of us









Invitation to join us

Open source collaboration





























- Find out more and contact me
 - Papyrus IC Research & Academia Committee
 - https://wiki.polarsys.org/Papyrus IC
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